## G ate-Voltage Studies of D iscrete E lectronic States in A 1N anoparticles

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We have investigated the spectrum of discrete electronic states in single, nm-scale Alparticles incorporated into new tunneling transistors, com plete with a gate electrode. The addition of the gate has allowed (a) measurements of the electronic spectra for dierent numbers of electrons in the same particle, (b) greatly in proved resolution and qualitatively new results for spectra within superconducting particles, and (c) detailed studies of the gate-voltage dependence of the resonance level widths, which have directly demonstrated the e ects of non-equilibrium excitations.

Recently it has become possible to measure the discrete spectrum of quantum energy levels for the interacting electrons within single sem iconductor quantum dots [1] and nm -scalem etalparticles [2 { 4 ], and thereby to investigate the forces governing electronic structure. Our earlier experiments on Alparticles were performed with simple tunneling devices, lacking a gate with which the electric potential of the particle could be adjusted. In this Letter, we describe the fabrication and study of nanoparticle transistors, com plete with a gate electrode. This greatly expands the accessible physics. We have used the gate to tune the number of electrons in the particle, so as to m easure excitation spectra for di erent num bers of electrons in the same grain and to con m even-odd e ects. The gate has also allowed signi cantly improved spectroscopic resolution, providing new understanding about the destruction of superconductivity in a nm -scale m etal particle by an applied magnetic eld. Studies of the gatevoltage dependence of tunneling resonance widths have shown that non-equilibrium excitations in the nanoparticle are a prim ary source of resonance broadening.

A schematic cross-section of our device geometry is shown in Fig. 1(a). The gate electrode forms a ring around the Alnanoparticle. The devices are fabricated by rst using electron beam lithography and reactive ion etching to make a bow I-shaped hole in a suspended silicon nitride m em brane, with an ori ce between 5 and 10 nm in diam eter [5]. The gate electrode is form ed by evaporating 12 nm of Alonto the at (lower in Fig. 1 (a)) side of the m em brane. P lasm a anodization and deposition of insulating SiO are then used to provide electrical isolation for the gate. We next form an alum inum electrode which lls the bow I-shaped side (top in Fig. 1(a)) of the nitride membrane by evaporation of 100 nm of Al, followed by oxidation in 50 m torr  $O_2$  for 45 sec to form a tunnel barrier near the low er opening of the bow 1-shaped hole. We create a layer of nanoparticles by depositing 2.5 nm of Alonto the lower side of the device; due to surface tension the metal beads up into separate grains less than 10 nm in diameter [6]. In approximately 25%

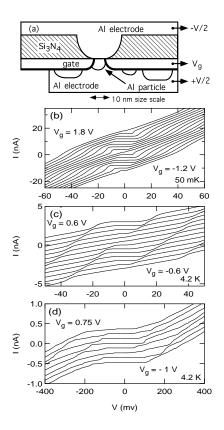


FIG.1. (a) Schem atic cross section of device geometry. (b)-(d) Current-voltage curves displaying Coulom b-staircase structure for three di erent sam ples, at equally spaced values of gate voltage. D ata for di erent  $V_g$  are arti cially o set on the current axis.

of the sam ples (determ ined as those show ing C oulom bstaircase" structure as described below), a single particle form s under the nm-scale tunnel junction to contact the top Alelectrode. Finally, after a second oxidation step to form a tunnel junction on the exposed surface of the particle, a low er electrode is form ed by evaporating 100 nm of Alto cover the particle. W em easure electron tunneling between the top and bottom electrodes, through a single nanoparticle, as a function of gate voltage, V<sub>g</sub>.

The devices can be characterized by measuring largescale current vs. source-drain voltage (I-V) curves for a series of  $V_g$  (Fig. 1(b)-(d)). The form of these curves, with zero current at low jV j (the \C oulom b blockade"), sloping steps equally spaced in V, and step thresholds sensitive to  $V_g$ , is indicative of single-electron tunneling via one nanoparticle [7]. From the positions of the voltage thresholds for steps in the I-V curve, we can determ ine

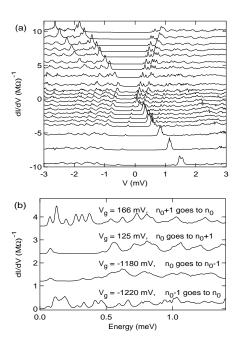


FIG.2. (a) dI=dV vs.source-drain voltage, plotted for  $V_g$  ranging from 75 mV (bottom) to 205 mV (top), for the device of Fig.1(b). Curves are o set on the dI=dV axis. (b) Tunneling spectra for this sample, labeled by the number of electrons in the initial and nal states. ( $n_0$  is odd) All data are for T = 50 mK, H = 0.05 Tesla, to drive the Alleads norm al.

the capacitances within the device [8]. For Fig. 1(b), the lead-to-particle capacitances are  $C_1 = 3.5$  aF and  $C_2 = 9.4$  aF, and the gate-to-particle capacitance is  $C_g = 0.09$  aF; for Fig. 1(c) the capacitances are 3.4, 8.5, and 0.23 aF, and for Fig. 1(d) 0.6, 1.0, and 0.13 aF. The charging energy,  $E_c = e^2 = (2C_{total})$ , for these devices is relatively large { for the device of Fig. 1(d),  $E_c = 46$  m eV (corresponding to T 500 K), com parable to the largest blockade energy measured for any single-electron transistor [9].

The nanoparticle size can be estimated using a value for the capacitance per unit area, 0.075 aF  $/\text{nm}^2$ , determined from larger tunnel junctions made using our oxidation process. If we make the crude assumption of a hem ispherical particle shape, and base the estimate on the larger lead-to-particle capacitance, we estimate radii of 4.5, 4.3, and 1.5 nm, respectively, for Fig. 1(b)-(d).

To measure the discrete electronic states within the nanoparticle, we cool the devices to mK temperatures and measure dI=dV vs. V in the range of the rst C oulom b-staircase step (Fig. 2 (a)). Peaks in dI=dV are expected whenever the Ferm i level in one of the two leads becomes equal to the threshold energy for an electron to tunnel either into or out of one of the discrete states within the particle, through one of the two tunnel junctions [10]. The interpretation that the data in Fig. 2 (a) are due to tunneling via states in a single nanoparticle is

con med by the uniform shifting of the peaks with  $V_g$ . All the dI=dV peaks shift linearly in V as a function of  $V_g$ , with tunneling thresholds across junction 1 allm oving with a single slope, V ( $C_g=C_2$ ) V<sub>g</sub>, and thresholds across junction 2 m oving as V ( $C_g=C_1$ ) V<sub>g</sub>. Due to the large charging energy in this device, electrons m ust tunnel one at a time through the particle in the V range displayed in Fig. 2 (a). This means that at xed V<sub>g</sub> all the peaks associated with the same junction are due to states with the same number of electrons.

As  $V_q$  is increased in Fig. 2(a), the extent of the Coulom b blockade region at low JV j decreases, goes to 0, and then increases. This zero-crossing indicates that an electron is added to the particle. If  $n_0$  is the num ber of electrons in the ground state at  $V_g = V = 0$ , then the tunneling processes which overcome the Coulomb blockade correspond in the bottom half of Fig. 2(a) to  $n_0 ! (n_0 + 1)$ -electron transitions, and in the top half of the gure to  $(n_0 + 1)$ !  $n_0$  transitions. The  $n_0$ !  $(n_0 + 1)$ and  $(n_0 + 1)$ !  $n_0$ -electron spectra can be determined m ost easily from the lower left and upper right quadrants of Fig. 2 (a), respectively. In these quadrants, the tunneling step which overcom es the Coulom b blockade occurs across the higher resistance junction [11], so that tunneling across this junction is always the rate-lim iting step for current ow . All the peaks in dI=dV correspond to states which provide alternative tunneling channels across this one junction. In the other two quadrants, thresholds for tunneling across both tunnel junctions, i.e. for both  $n_0 ! (n_0 + 1)$  and  $(n_0 + 1) ! n_0$  processes, are visible.

In Fig. 2(b), we display several tunneling spectra for di erent num bers of electrons in the same particle. (W e discuss the signi cance of these spectra below .) Fig. 3 shows the magnetic-eld (H) dependence of the levels which can be resolved in the upper two curves of Fig. 2(b). In both Figs. 2(b) and 3, we have converted from source-drain bias to electron energy, multiplying by  $eC_2 = (C_1 + C_2) = 0$ :73e to account for the capacitive division of V across the two tunnel junctions. The values of  $V_q$  were chosen so that the spectra were measurable at low values of  $\frac{1}{2}$  is where they are best resolved. As a function of H, the energy levels are shifted approxim ately linearly, with Zeem an splittings corresponding to g values between 1.95 and 2. Energy levels which move to higher energies with increasing H produce broader, less distinct dI=dV peaks than dow nw ard-m oving levels (for reasons poorly understood), and can be followed for only a lim ited range of H before they are lost in background. In our previous superconducting particles, without gates, most upward-moving levels could not be resolved at all. This caused us to incorrectly assign anom alously low gfactors to som e states [3].

A s described previously [2], the electron-num berparity in the ground state of a particle can be determined by whether the lowest-energy tunneling level exhibits Zeem an splitting (even parity) or not (odd). In this way we can tell that  $n_0$  is odd in Fig. 3(a) and  $n_0 + 1$  is even in Fig. 3(b). While tuning  $V_{q}$ , we have observed parity

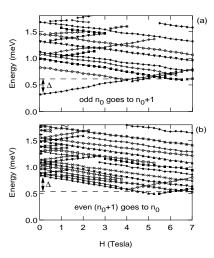


FIG.3. M agnetic eld dependence of the resolved electronic states for the device of Fig.2 at (a)  $V_g$  = 110 mV and (b)  $V_q$  = 181 mV.

changes only when electrons are added to the particle at the zero-crossings of the Coulomb blockade. The parity simply switches from even to odd to even, etc., at consecutive blockade minima. The nanoparticle therefore exchanges electrons only with the electrodes, and not with any nearby defects.

The ability to tune the num ber of electrons in a particle using  $V_q$  allows us for the rst time to study the dramatic di erences between tunneling spectra for even and odd num bers of electrons in the sam e superconducting particle [3]. The large gap between the low est energy level and all the others in the  $n_0 ! n_0 + 1$  and  $n_0 ! n_0 - 1$  spectra (Figs. 3 (a) and 2 (b)) can be explained by superconducting pairing. The tunneling states in these spectra have an even number of electrons, so that the lowest level is the fully paired superconducting state. Tunneling via any other state requires the production of at least two quasiparticles, with a large extra energy cost approximately twice the superconducting gap, . The n  $_0$  + 1 !  $n_0$ 1 ! n<sub>0</sub> tunneling states have an odd num and n<sub>0</sub> ber of electrons, and they all must contain at least one quasiparticle. Hence there is no large gap within these spectra. However, the contribution of to the quasiparticle energy causes the low-lying tunneling levels at low H to have energies greater by than at large H, where superconductivity is suppressed. The rst tunneling thresholds in Fig. 3 (a) and (b) have exactly the same H dependence, with opposite sign, because they correspond to the lling and emptying of the same quantum states. In Fig. 3, 0.3 m eV, com parable to previous results [3].

The levels in Figs. 3(a,b) provide new insights as to how a magnetic eld destroys superconductivity in a nanoparticle. Consider the second level at small H in Fig. 3(a), which begins near 0.8 meV. This state shifts

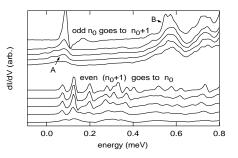


FIG.4. Tunneling resonances broaden and develop substructure as V<sub>g</sub> is used to shift them to larger values of jV j. The top scan in both sets corresponds to a value of V<sub>g</sub> which allows the spectrum to be measured with minimum jV j.Going down, other scans are for V<sub>g</sub> requiring extra source-drain voltages jV j= 0.2, 0.4, 0.6, and 1.2 mV. The scans are arti cially shifted in energy to align peaks due to the sam e eigenstates. T = 50 m K, H = 0 for all scans, and the sam ple is the sam e as in Figs.2 and 3. Peaks A and B are discussed in the text.

down as a function of H , due to its spin-1/2 Zeem an energy, up to 4 Tesla. There it disappears in favor of a new upward-moving (opposite spin-1/2) level. This m eans that the originally-empty dow nw ard-trending level drops below the energy of an originally-lled upwardtrending level, and an electron is transferred between the states. The odd-electron ground state changes its spin from 1/2 to 3/2 h. As this process is repeated, the tunneling threshold moves in a continuous zig-zag pattern, and the ground state successively increases its spin in units of h. A similar argument for Fig. 3(b) shows that the even-electron ground state also evolves by individual spin ips. Superconductivity is destroyed as electrons ip one at a time. In contrast, the classic theories of C logston and C handrasekhar [12], for a superconducting transition driven by spin pair-breaking, predict a large discontinuous jum p in the tunneling threshold, at a eld where many spins ip simultaneously. Investigations are underway as to whether these theories do not properly take into account the e ect of discrete electronic energy levels in the particle [13], or perhaps whether the experim ental transitions are m ade continuous by a contribution from orbital pair breaking [14].

We have shown that changes in  $V_g$  act to shift the electrostatic energy of the eigenstates on the nanoparticle, and thereby shift the value of V at which a given state produces a peak in dI=dV (see Fig. 2(a)). In Fig. 4, we exam ine m ore closely how the shapes of resonances change as they are m oved to larger values of jV j. The top spectrum in each set of traces corresponds to a value of  $V_g$ which places the rst tunneling peak at the sm allest possible jV j[15]. The low ercurves show the results of tunneling via the same quantum states, after their dI=dV peaks have been shifted to successively larger jV j. To aid com – parison, we have aligned the spectra, so that the shifts

in j jare not displayed explicitly. W e show data for superconducting electrodes (H = 0) because the BCS singularity in the density of states in the electrodes in proves spectroscopic resolution [2]. Focus rst on the lowest energy level for  $n_0 ! n_0 + 1$  (odd-to-even) electron tunneling. In equilibrium, this is necessarily a single, nondegenerate state { the fully-paired superconducting state. Indeed, for the low est-1/ jtrace (top curve), this level produces a single sharp signal (whose shape is given by the derivative of the BCS density of states in the Alelectrode [2]). However, as  $V_q$  is used to shift this rst state to larger j / j the resonance quickly broadens and develops substructure. The substructure cannot be explained by heating in the electrodes. Instead, it is evidence for the in portance of non-equilibrium excitations within the particle [4]. W hen electrons are tunneling via even the low est level in the  $n_0 ! n_0 + 1$  spectrum, the current ow will naturally generate non-equilibrium excitations within the particle when the excess source-drain energy, e(  $\sqrt[1]{}$ , is greater than the di erence between the rst two levels in the measured  $n_0 + 1! n_0$  spectrum ( 0.05 m eV). This happens because one electron can tunnel from the highenergy electrode into the empty level in the particle, and then an electron can exit to the other electrode from a different, low er-energy  $(n_0 + 1)$ -electron led state, leaving a hole. If the resultant electron-hole excitation does not relax before the next electron tunnels onto the particle 10<sup>8</sup> s), its presence can produce sm all shifts in (e=I the tunneling energies available for the next electron. For very sm all particles, it has been proposed that the tim eintegrated result for an ensemble of possible excitations will be a well-resolved cluster of tunneling resonances associated with each single-electron level [4]. For particles large enough to exhibit superconductivity, we propose that the di erent non-equilibrium resonances are not so well resolved, but overlap to produce broadened dI=dV peaks.

In sharp contrast to the  $n_0 ! n_0 + 1$  spectrum, the low-energy peaks in the  $n_0 + 1 ! n_0$  spectrum do not show increasing widths as long as j y j = 0.6 meV, but then they do broaden for larger j y j. This is additional evidence for the role of non-equilibrium excitations in resonance broadening, because the condition necessary for producing non-equilibrium excitations in the particle during measurement of these  $n_0 + 1 ! n_0$  states is that e(j y j) must be greater than the di erence between the rst two levels in the  $n_0 ! n_0 + 1$  spectrum ( 0.55 meV).

In the raw data, the rst peak (A) in the jV j = 0.6 mV scan of the  $n_0 ! n_0 + 1$  spectrum in Fig.4 and the second peak (B) in the jV j = 0 scan of the same spectrum occur at the same value of V, so the degree of non-equilibrium in the particle should be sim ilar. The e ective widths of these dI=dV peaks are nearly the same. This suggests that the non-equilibrium e ect is also a dom inant source of broadening for the higher-energy resonances, even in the jV j = 0 spectrum.

In summary, we have produced tunneling transistors

containing single Al nanoparticles, and have measured the discrete spectra of energy levels in the particle while tuning the number of electrons it contains. We have directly demonstrated di erences in level spectra for even vs.odd numbers of electrons, which can be explained as an e ect of superconducting pairing interactions. The application of a magnetic eld destroys superconductivity in the nanoparticle by a sequence of individual spin ips. The tunneling resonances broaden and develop substructure when the source-drain voltage becom es large enough to allow the production of non-equilibrium excitations within the particle.

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